

The 10th Advanced Lasers and Photon Sources ALPS 2021

Sponsored by
The Laser Society of Japan



Conference Co-Chair **Hitoki Yoneda**

Institute for Laser Science, University of Electro-Communications

We are delighted to welcome you to the 10th Advanced Lasers and Photon Sources Conference (ALPS 2021).

It is great pleasure for us to have the 10th anniversary conference ALPS in this year. From the start year, ALPS conference is keeping to cover the science and technology related to lasers and photon sources, related basic research and industrial applications. As well known, excellent light sources are key components and technologies to promote and develop new scientific field and many applications. Role of the ALPS is exchanging the idea and the information related to these sophisticated light sources and new applications. This is the main reason why we can keep attractive conference condition during these ten years.

The ALPS conference is organized as part of the OPTICS & PHOTONICS International Congress (OPIC 2021), which consists of twelve optics-related scientific conferences. In the 10th ALPS we will have more than 100 excellent presentations to cover the recent advanced in this scientific field including 26 invited talks. The field included are novel optical materials, high average power lasers, high peak power lasers, novel solid-state, fiber, diode lasers, shorter wavelength light sources, terahertz devices, novel optical devices, optical frequency combs and their applications.

People knows that we still have severe limitation to move to the abroad and held the face-to-face conference due to the COVID-19. However, scientist's interests can exceed this limit and we believe we will have fruitful discussion time in 10th ALPS meeting. You are very welcome to join us and to enjoy your time at the ALPS conference.

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